

Fig.1A

FORMATION OF INSULATING FILM
(COATING/BAKING)

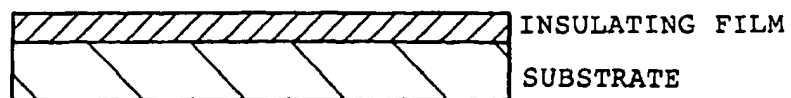


Fig.1B

RESIST COATING/PRE-BAKING

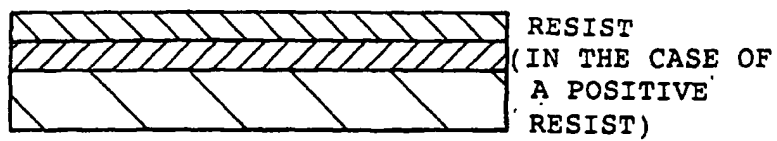


Fig.1C

MASK ALIGNMENT/EXPOSURE

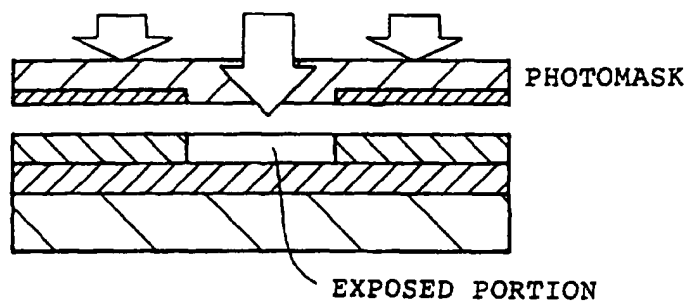


Fig.1D

RESIST DEVELOPMENT/POST-BAKING

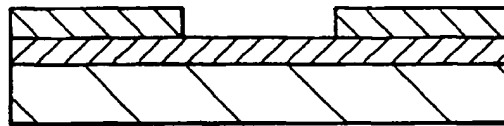


Fig.1E

INSULATING FILM ETCHING

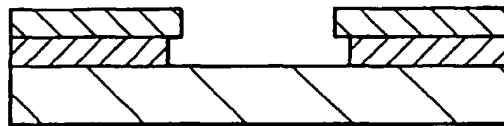


Fig.1F

RESIST ASHING



